


文件名稱： 設備作業標準(CF-T29 8 吋金屬物理氣相沉積系統)  
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 制訂部門： 蝕刻薄膜組  
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文件制修訂記錄

版本	編製者	生效日期	核定文號	改版/變更說明	修訂頁次
1.0	楊雲凱	2019-02-20	IS108006	制定新版	---
1.1	楊雲凱	2025-04-29	IS114012	1. 配合本院企業識別變更為 NIAR，更新文件的企業識別。 2. 修訂文件編號以 10 碼為標準，新增前 4 碼 TSRI。	全

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一、 目的：定義 8 吋金屬物理氣相沉積系統操作規範，以確保操作品質。

二、 範圍：8 吋金屬物理氣相沉積系統(8 吋 PVD)


三、 權責：

1. 組織權責：工程師負責制定及修改規範。
2. 執行人員資格：8 吋金屬物理氣相沉積系統(8 吋 PVD)考核通過之人員。

四、 名詞定義：無

五、 相關文件：無

六、 標準作業程序：

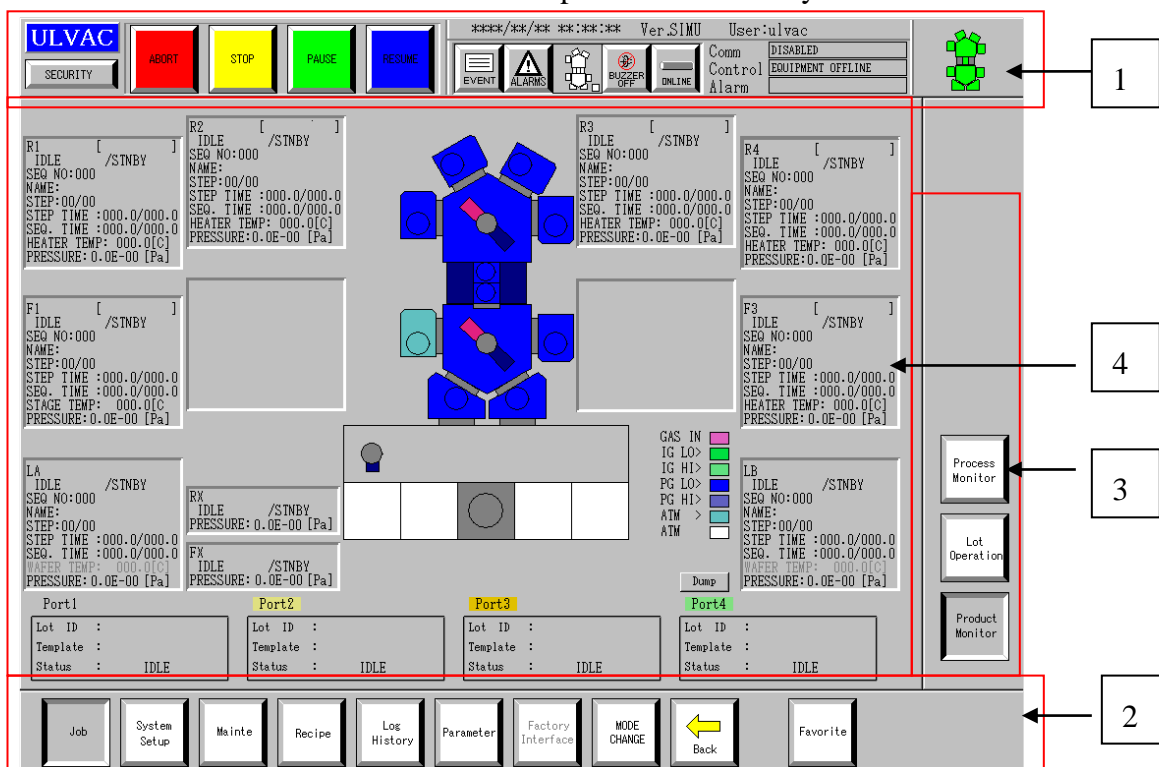
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## 8 吋金屬物理氣相沉積系統 (8 吋 PVD)

### 標準製作程序

#### (一)、How to use the CTC(Cluster Tool Controlle) screen

The CTC screen is divided into multiple areas divided by frames.



The CTC screen layout

#### 1. Title panel


Located at the top of the screen and includes the function buttons commonly used for all operations, and an alarm information area. See “Fig. 3-3 Title panel” for detail of buttons.

#### 2. Navigation panel

Located at the bottom of the screen and includes the menu buttons.

Clicking on these button changes the menu button displayed on the command panel. The menu button referring to the display on the information panel turns dark gray to indicate that it is selected.

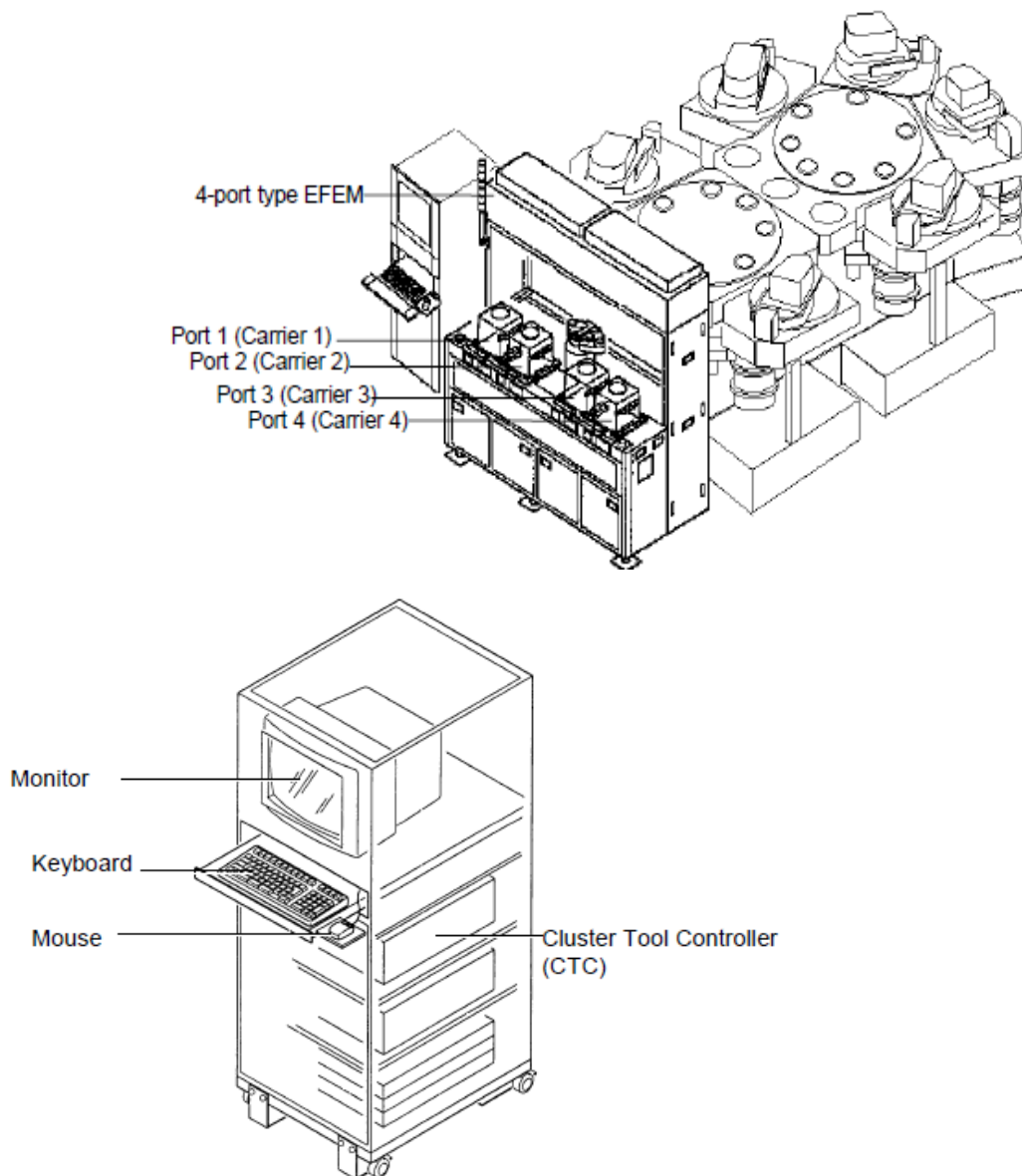
#### 3. Command panel

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Located on the right side of the screen. The buttons on the command panel change according to the menu button selected on the navigation panel. The menu button referring to the display on the information panel turns grey to indicate that it is selected.

#### 4. Information panel

Located in the center of the screen, this panel displays the settings and other information specified on the navigation panel and command panel. The information panel consists of a graphical image operation area and/or text entry fields.



#### 5. Title panel

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(1).Chamber navigation area


The configuration of all modules being controlled is displayed in this chamber navigation.

Many different types of operation windows provided to the CTC screen display information specific to each module. Selecting a specific module from the chamber navigation area highlights the modules and changes the information on each operation window to that corresponding to the selected module.

(2)..System control area

The buttons allow package operation of integrated modules at for all modules.

<SECURITY> button	Press this button to log on, log off, close and shut down. Entering a user name and password enables operations at each security level.
<ABORT> button	Immediately stops all lot operations in progress at all modules. (*2) Checking dialog box is displayed by the [Definition] window setting.
<STOP> button	Stops all lot processes in progress at all modules. The wafers that have been started the operation stop all processes.
<PAUSE> button	Suspends all lot operations in progress at all modules after they have proceeded to the process completion currently in progress.
<RESUME> button	Continues all the suspended lot operation.

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### (3). System status area


The current date, time, CTC softwafer version and operator name are displayed.

Date	Displayed in “YYYY/MM/DD/” or “MM/DD/YYYY” by the [Definition] window setting. (YYYY: year / MM: month / DD: day)
Time	Displayed in “HH:MM:SS”. (HH: hour / MM: minute / SS: second)
CTC version	Displays the version No. of the software.
Operator name	Displays the “Log ID” of the operator who has logged in on the [SECURITY] window. “Unknown” is displayed before “Login

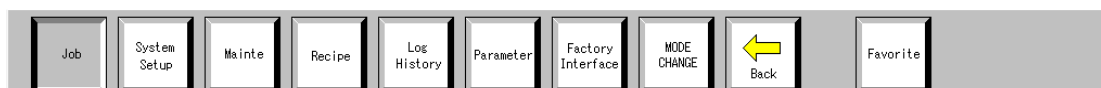
### (4). Alarm information area Displays the information of alarms given off in the system.

Provided are the <ALARMS> button to check details of alarm information and the <BUZZER OFF> button that cancels the buzzer sounded when alarm occurs.

<EVENT> button	Displays the [Event] window that displays action event log by each module unit.
<ALARMS> button	Displays the [Alarm] window that allows operators to check all alarm information currently occurring in the system.
Alarm-issue module	Displays the module in which alarm occurred. Module colors change with the level (severity) of an alarm that occurred at the time. Red : Error Yellow : Warning (White : No alarm issued)
<BUZZER OFF> button	Turn off the buzzer that sounds when alarm occurs. This button also turns off the chime sounded when the sequence of auto operation command is finished.

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## (二)、Navigation panel



Menu button	Function
<Job>	Edits and stores a new lot operation or carries the lot operation already stored. Also, monitors lot processing or system state using graphics or status.
<System Setup>	Set up system by system. Executes auto operation of each system except for lot processing.
<Mainte>	Manually operates each module or each device. Also, executes and checks recovery operation from troubles and communication command-level operation.
<Recipe>	Creates and edits process conditions for lot processing, such as sequence, flow and template. Also, sets alarm level, auto cleaning and others.
<Log History>	Checks a list of the past lot log data and details of process data. Also, compare data of wafers of each lot, creates a graph according to the result of comparison and verifies the data.
<Parameter>	Verifies and edits system configuration/definition parameters or different type of operation parameters, and backs up these parameters.
<Factory Interface>	Sets parameters related to online, and confirms the status of various status.
<MODE CHANGE>	Sets the operation mode for each module.


### <Back window> button

Stores and displays the maximum of 10 windows displayed in the past.

### <Favorite> button

Calls and displays the window registered in advance from the list. 10 windows can be registered in the list as optional and allows operators to call a desired window without using each button on the command panel.

The registered each users can set this function respectively.

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### Job


Product Monitor	Monitors the operating state of the entire system on one screen.
Lot Operation	Processes and controls lots.
Process Monitor	Displays the process status of the system.
Load Port Monitor	Monitors the status of Load Port for each Load Port.

### System Setup

Auto Macro	Executes marco in multiple modules in Auto Mode.
Service Macro	Executes macro in each module in Service Mode.
Auto Menu	Executes Auto Menu in multiple modules. Parallel operation is also possible.
Service Status	Views service parameters for each module.
QC Data	Checks the QC data (film thickness).

### Mainte

Module Operation	Operates in manual the device on the system for each device or unit. Semi auto is performed as well.
Module Transfer	Transfers wafers one by one.
Manual Process	Displays manual-operation menu buttons to service each device/unit in the system.
Wafer Recovery	Recovers wafers as required.
I/O Operation	Executes forcibly manual operation of module digital output (DO) and analog output (AO) and checks the real-time state of digital input/output (DI/O) and analog output/input (AI/O).
Serial Operation	Checks and manually operates, the state of device/unit of the system to use the serial communication.
Vacuum Operation	Operates vacuum system for the entire system.
EFEM Operation	Edits various operation parameters for EFEM.
Wafer Trasfer	Trasnfers wafers between EFEM Port.
Life Test	Executes transfer and reliability tests without supplying the power according to recipe conditions.

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Data Record	Displays in graphs the analog input value data according to the time elapsed.
Robot Test	Operates the robot on vacuum side by command level and checks the teaching data.
Serial Monitor	Checks the transmitting/receiving data of serial communication command.
ID Reader Test	Not supported. Performs various setting and action checking of the ID Reader.
AMHS Test	Set signals for automated material handling system (AMHS) and this system.

#### Recipe


Sequence	Edits the sequence of a module selected from the module navigation area.
Flow	Edits how to flow wafers to be processed through process modules (process flow).
Template	Edits and stores lot processing parameters as a template according to multiple wafer types composing a carrier to be processed.
Alarm Level	Sets the error range according to the sequence settings.
SMC Template	Sets and edits the template used for SMC.

#### Log History


Logging Data	A list of the past log data and details of process data can be viewed and checked. Also, data of wafers in a lot can be graphed to compare.
Alarm	Displays a list of alarm issued in the past.
Event	Displays a list of generated events.
SMC Logging Data	Views the logging data related to the SMC processing and details of process data.

#### Parameter

Process Parameter	Verifies and edits process parameters.
Sequence Parameter	Sets parameters used to the semi auto movement.

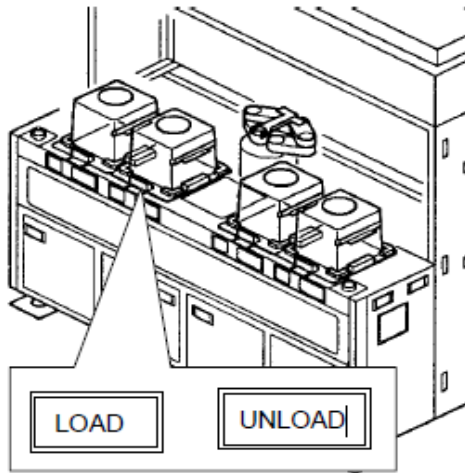
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Service Parameter	Sets and checks the state of monitoring devices of utilities, targets, devices, etc.
Heater Parameter	Edits setup sequence parameters for process heater and others of a module selected from the module navigation area.
Esc Parameter	Sets multiple patterns of electrostatic chuck On/Off sequences when process is in progress.
Depo Rate Parameter	Sets parameters for deposition rate for each sputtering module.
System Parameter	Presetting the power supply type, heater type, gas line type and others controls the module according to its particular specification.
Timer	Sets the timer used in the software for menu operation and device operation.
Calibration	Not supported. Sets RF power supply calibrated data and process heater temperature calibrated data.
AI/O Max	Presets the maximum value of controllable range for each analog device.
Auto Macro Parameter	Sets auto macro of System Setup menu.
Service Macro Parameter	Sets service macro of System Setup menu.
Definition	Sets parameters related to the entire system, such as system configuration parameter.
Option	Not supported. Sets parameters for system options.
Password	Defines restrictions on windows available for operators.
Cryo Parameter	Sets parameters related to the Cryo pumping down system of the transfer module.
AMHS Parameter	Defines signals for automated material handling system (AMHS).
Transfer Parameter	Not supported. Defines the scheduler for wafer transfer control.

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(三)、Lot processing by local operation

1. Carrier Setting



2. Input the “Carrier ID”


3. Edit Recipe

(1)、Edit sequence

(2)、Edit Flow

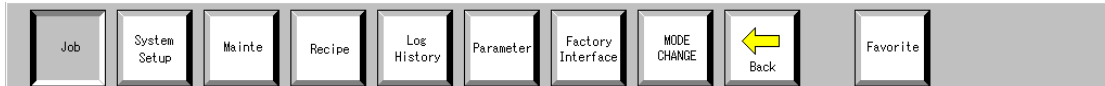
(3)、Edit and Execute Lot Processing

Press the <Create Que> button on the [Lot Operation] window

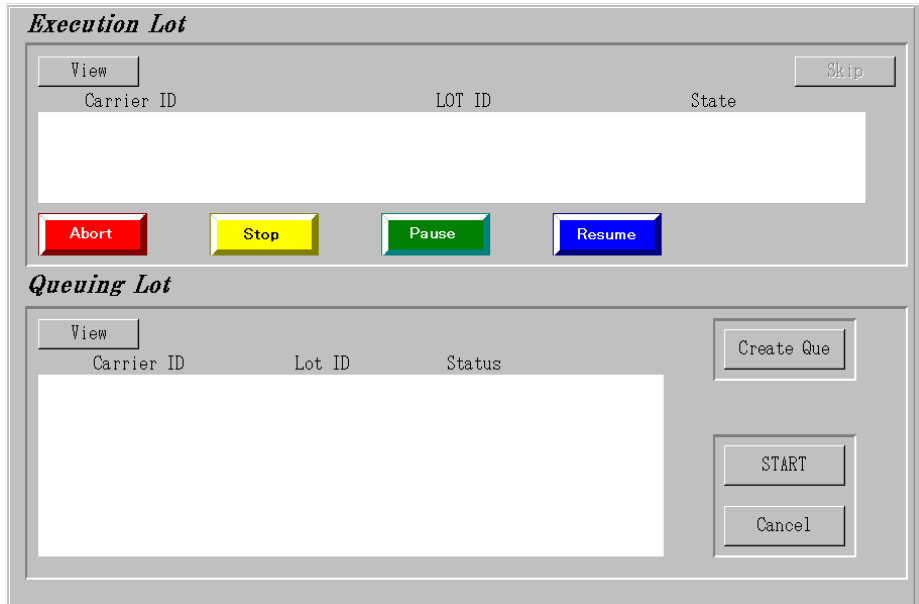
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(四)、Lot Execution

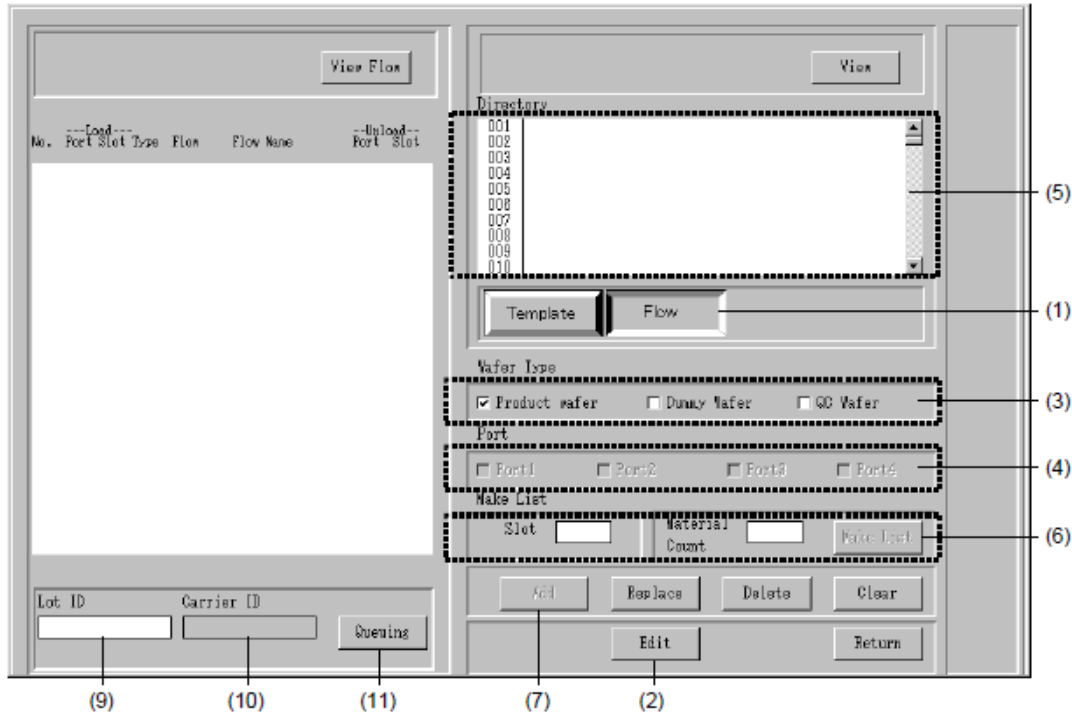
Select the **Job** button on the navigation panel, and select the **Lot Operation** button on the command panel.




Press the **Create Que** button on the [Lot Operation] window



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1. Select the flow by the <Template/Flow> changeover button.  
→ The list displayed in the [Directory] area is changed to the flow.
2. Select the <Edit> button on the [Queuing (Template)] window.  
→ It becomes possible to edit the template and flow.
3. Select the wafer type. Select the wafer type from the among the product wafer, dummy wafer and QC wafer.
4. Select the port whose carrier is set. (port1.~4.)
5. Select the Flow to use from (001~250)
6. Set the slot No. whose flow is set.(1.~25.)
7. Select the <Add> button.  
→ The flow contents selected in the [Dierctory] area is displayed in the [Template Information] area.

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8. Repeat the step (5), (6) and (7) and set the flow to each slot
9. Move the mouse pointer to the “Lot ID”  
→ The contents thus defined are displayed in the [Lot ID] and cursor moves to the [Carrier ID].
10. Input the “Carrier ID” from the keyboard. After input, press the <Enter> key to define it.  
→ The contents thus defined are displayed in the “Carrier ID”

七、 應用表單及附件：

- 7.1 TSRI-Q4-NL02 設備管理卡
- 7.2 TSRI-Q4-NL03 設備考核表
- 7.3 TSRI-Q4-NL04 設備點檢表
- 7.4 TSRI-Q4-NL05 異常及矯正預防處理單